

# INEL 6055 Homework No. 1

Due February 2

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For the following problems refer to the semiconductor resistor designed in the example on section 1.1.2 of the lecture notes. It is acceptable to substitute finite differences for partial derivatives or to calculate partial derivatives graphically.

1. Determine the surface donor concentration if the conductivity profile shown in figure shown on figure 2 correspond to an N-type device. (10 points)
2. Estimate the temperature coefficient of the  $100k\Omega$  resistor. The temperature coefficient is defined as

$$\alpha = \frac{1}{R_0} \frac{\partial R}{\partial T}$$

Assume room temperature (300K) and that the linear thermal expansion coefficient of Silicon is  $3 \times 10^{-6}$  parts per degree Kelvin. (20 points)

3. Find the voltage that, when applied to the resistor, will increase the room-temperature incremental resistance to twice its nominal value. (20 points)

$$\textcircled{1} \quad \sigma_0 = 10 (\Omega \cdot \text{cm})^{-1} = q N_D \mu_n$$

$$\text{Using } \mu_n = 1450 \text{ cm}^2/\text{V}\cdot\text{s} \Rightarrow N_D = \frac{10 (\Omega \cdot \text{cm})^{-1}}{(1.6 \times 10^{-19} \text{ C})(1450 \frac{\text{cm}^2}{\text{V}\cdot\text{s}})}$$

$$N_D \approx 4.3 \times 10^{16} \text{ cm}^{-3}$$

$$\textcircled{2} \quad R = \frac{L}{\sigma x_j w} \Rightarrow \alpha = \frac{1}{R_0} \frac{\partial R}{\partial T} = \frac{1}{R_0} \left[ \frac{1}{\sigma_0} \frac{\partial}{\partial T} \left( \frac{L}{x_j w} \right) + \frac{L}{x_j w} \frac{\partial}{\partial T} \left( \frac{1}{\sigma} \right) \right]$$

$$\text{Let } R_0 = \frac{L}{\sigma_0 x_j w}$$

$$\alpha = \frac{\frac{1}{\sigma_0} \frac{\partial}{\partial T} \left( \frac{L}{x_j w} \right)}{\frac{1}{\sigma_0} \frac{L}{x_j w}} + \frac{\frac{L}{x_j w} \frac{\partial}{\partial T} \left( \frac{1}{\sigma} \right)}{\frac{L}{\sigma x_j w}}$$

$$= \frac{1}{3 \times 10^{-6} \text{ K}^{-1}} + \frac{\frac{1}{\sigma} \frac{\partial \sigma}{\partial T}}{\frac{\sigma}{\sigma}}$$

$$\therefore \alpha = 3 \times 10^{-6} + \frac{1}{\sigma} \frac{\partial}{\partial T} \frac{1}{\sigma}$$

$$\sigma \approx q \mu_n N_D$$

Since  $q$  is a constant and all donors are ionized at room temperature,

$$\sigma(T) = q N_D [\mu_n(T)]$$

$$\frac{\partial}{\partial T} \frac{1}{\sigma} = \frac{\partial}{\partial \sigma} \left( \frac{1}{\sigma} \right) \frac{\partial \sigma}{\partial T} = -\frac{1}{\sigma^2} \frac{\partial \sigma}{\partial T}$$

$$\begin{aligned} \alpha &= 3 \times 10^{-6} \text{ K}^{-1} - \left( \frac{1}{\sigma} \right) \frac{\partial \sigma}{\partial T} \\ &= 3 \times 10^{-6} \text{ K}^{-1} - \frac{1}{q N_D \mu_n} q N_D \frac{\partial \mu_n}{\partial T} \\ &= 3 \times 10^{-6} \text{ K}^{-1} - \frac{1}{\mu_n} \frac{\partial \mu_n}{\partial T} \end{aligned}$$

$$\text{Use } \mu_n = 88 T_n^{-0.57} + \frac{1250 T_n^{-2.33}}{1 + \left( \frac{N}{1.26 \times 10^{17} T_n^{2.4}} \right) 0.88 T_n^{-0.146}}$$

$N$  = average donor conc.

Since  $\bar{\sigma} = 4.18 (\Omega \cdot \text{cm})^{-1}$  (from example; see page 3 notes)

$$\begin{aligned} \bar{\sigma} &= q \mu_n \bar{N}_D \Rightarrow \bar{N}_D = \frac{4.18 (\Omega \cdot \text{cm})^{-1}}{(1.6 \times 10^{-19} \text{ C}) (1450 \text{ cm}^2/\text{V}\cdot\text{s})} \\ &= 1.8 \times 10^{16} \text{ cm}^{-3} \end{aligned}$$

$$\mu_n = 88 T_n^{-0.57} + \frac{1250 T_n^{-2.33}}{1 + \left( \frac{0.143}{T_n^{2.4}} \right) 0.88 T_n^{-0.146}}$$

$$\text{Use } \frac{\partial \mu_n}{\partial T} \approx \frac{\Delta \mu_n}{\Delta T}$$

for  $T_n = 1 \pm 1.01$  ( $300^\circ\text{K}$  &  $303^\circ\text{K}$ )

$$\frac{\partial \mu_n}{\partial T} \approx -7.63$$

$$\alpha \approx 3 \times 10^{-6} \text{ K}^{-1} - \frac{1}{1450} (-7.63) = 3 \times 10^{-6} \text{ K}^{-1} + 5.3 \times 10^{-3} \text{ K}^{-1}$$

1845  $\rightarrow$  Si Chip resistors:  $\alpha \sim 1.02\% / ^\circ\text{C}$

$\rightarrow$  OK

$$\boxed{\alpha \approx 5.3 \times 10^{-3} \text{ K}^{-1}}$$

$$\textcircled{3} \quad R = \frac{L}{\sigma x_j W} = \frac{V}{I} = \frac{E/L}{j(x_j W)} = \frac{1}{x_j L W} \frac{E}{j} = \frac{1}{x_j L W} \frac{E}{q n v_d}$$

$$j = + q n v_d$$

$$\therefore R = \frac{1}{x_j L W} \left( \frac{1}{q n_d} \right) \frac{E}{v_d} = A \frac{E}{v_d}$$

The incremental resistance can be defined as

$$R' = \frac{\Delta V}{\Delta E} \quad (\text{slope around some operating point})$$

$$= A \frac{\Delta E}{\Delta v_d} \quad \rightarrow \text{for the resistance to double the slope of } \Delta v_d / \Delta E \text{ must be half}$$

$$v_d = v_{d1} \frac{E}{E_c} \left( \frac{1}{1 + (E/E_c)^{1.111}} \right)^{1/1.111}$$

For  $E \ll E_c$ ,  $v_d \approx v_{d1} \frac{E}{E_c} \leftarrow$  nominal value (low field)

$$\therefore \frac{\Delta v_d}{\Delta E} = \frac{v_{d1}}{E_c} = \frac{1.07 \times 10^8 \text{ cm/s}}{6910 \text{ V/cm}} = 1548.5 \frac{\text{V} \cdot \text{cm}^2}{\text{s}} \quad \rightarrow \text{slope at low field}$$

To numerically find the slope at a field  $E_1$

① determine  $v_{d1}$  at  $E_1$

② "  $v_{d2}$  at  $E_1 + \Delta E_1$  ( $\Delta E_1$  can be 1% of  $E_1$ )

$$\textcircled{3} \text{ find slope} = \frac{v_{d2} - v_{d1}}{(E_1 + \Delta E_1) - E_1} = \frac{v_{d2} - v_{d1}}{\Delta E_1}$$

We want to find  $E_1$  at which slope =  $\frac{1}{2} (1548.5) \approx 774.25$

I get about  $E_1 = 3281 \text{ V/cm}$

The voltage is  $V = (3281 \frac{\text{V}}{\text{cm}}) (125 \mu\text{m}) (10^{-4} \frac{\text{cm}}{\mu\text{m}})$

$$\boxed{V = 41 \text{ V}}$$